

**Formerly Available as FSS913A0R4,
Radiation Hardened, SEGR Resistant,
P-Channel Power MOSFETs**

The Discrete Products Operation of Intersil has developed a series of Radiation Hardened MOSFETs specifically designed for commercial and military space applications. Enhanced Power MOSFET immunity to Single Event Effects (SEE), Single Event Gate Rupture (SEGR) in particular, is combined with 100K RADS of total dose hardness to provide devices which are ideally suited to harsh space environments. The dose rate and neutron tolerance necessary for military applications have not been sacrificed.

The Intersil portfolio of SEGR resistant radiation hardened MOSFETs includes N-Channel and P-Channel devices in a variety of voltage, current and on-resistance ratings. Numerous packaging options are also available.

This MOSFET is an enhancement-mode silicon-gate power field-effect transistor of the vertical DMOS (VDMOS) structure. It is specially designed and processed to be radiation tolerant. The MOSFET is well suited for applications exposed to radiation environments such as switching regulation, switching converters, motor drives, relay drivers and drivers for high-power bipolar switching transistors requiring high speed and low gate drive power. This type can be operated directly from integrated circuits.

Also available at other radiation and screening levels. See us on the web, Intersil's home page: <http://www.intersil.com>. Contact your local Intersil Sales Office for additional information.

Ordering Information

PART NUMBER	PACKAGE	BRAND
JANSR2N7440	TO-257AA	JANSR2N7440

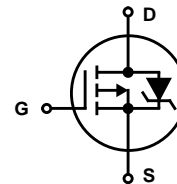
Die Family TA17796.

MIL-PRF-19500/659.

Features

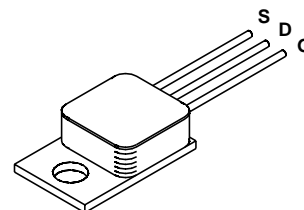
- 10A, -100V, $r_{DS(ON)} = 0.280\Omega$
- Total Dose
 - Meets Pre-RAD Specifications to 100K RAD (Si)
- Single Event
 - Safe Operating Area Curve for Single Event Effects
 - SEE Immunity for LET of 36MeV/mg/cm² with V_{DS} up to 80% of Rated Breakdown and V_{GS} of 10V Off-Bias
- Dose Rate
 - Typically Survives 3E9 RAD (Si)/s at 80% BV_{DSS}
 - Typically Survives 2E12 if Current Limited to I_{DM}
- Photo Current
 - 1.5nA Per-RAD(Si)/s Typically
- Neutron
 - Maintain Pre-RAD Specifications for 3E13 Neutrons/cm²
 - Usable to 3E14 Neutrons/cm²

Symbol



Packaging

TO-257AA



CAUTION: Beryllia Warning per MIL-S-19500 refer to package specifications.

JANSR2N7440

Absolute Maximum Ratings $T_C = 25^\circ\text{C}$, Unless Otherwise Specified

	JANSR2N7440	UNITS
Drain to Source Voltage	V_{DS}	-100 V
Drain to Gate Voltage ($R_{GS} = 20k\Omega$)	V_{DGR}	-100 V
Continuous Drain Current		
$T_C = 25^\circ\text{C}$	I_D	10 A
$T_C = 100^\circ\text{C}$	I_D	6 A
Pulsed Drain Current	I_{DM}	30 A
Gate to Source Voltage	V_{GS}	± 20 V
Maximum Power Dissipation		
$T_C = 25^\circ\text{C}$	P_T	56 W
$T_C = 100^\circ\text{C}$	P_T	22 W
Linear Derating Factor		0.45 W/ $^\circ\text{C}$
Single Pulsed Avalanche Current, $L = 100\mu\text{H}$, (See Test Figure)	I_{AS}	30 A
Continuous Source Current (Body Diode)	I_S	10 A
Pulsed Source Current (Body Diode)	I_{SM}	30 A
Operating and Storage Temperature	T_J, T_{STG}	-55 to 150 $^\circ\text{C}$
Lead Temperature (During Soldering) (Distance $>0.063\text{in}$ (1.6mm) from Case, 10s Max)	T_L	300 $^\circ\text{C}$
Weight (Typical)		4.4 g

CAUTION: Stresses above those listed in "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress only rating and operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied.

Electrical Specifications $T_C = 25^\circ\text{C}$, Unless Otherwise Specified

PARAMETER	SYMBOL	TEST CONDITIONS	MIN	TYP	MAX	UNITS	
Drain to Source Breakdown Voltage	BV_{DSS}	$I_D = 1\text{mA}, V_{GS} = 0\text{V}$	-100	-	-	V	
Gate Threshold Voltage	$V_{GS(TH)}$	$V_{GS} = V_{DS}, I_D = 1\text{mA}$	$T_C = -55^\circ\text{C}$	-	-	-7.0	V
			$T_C = 25^\circ\text{C}$	-2.0	-	-6.0	V
			$T_C = 125^\circ\text{C}$	-1.0	-	-	V
Zero Gate Voltage Drain Current	I_{DSS}	$V_{DS} = -80\text{V}, V_{GS} = 0\text{V}$	$T_C = 25^\circ\text{C}$	-	-	25	μA
			$T_C = 125^\circ\text{C}$	-	-	250	μA
Gate to Source Leakage Current	I_{GSS}	$V_{GS} = \pm 20\text{V}$	$T_C = 25^\circ\text{C}$	-	-	100	nA
			$T_C = 125^\circ\text{C}$	-	-	200	nA
Drain to Source On-State Voltage	$V_{DS(ON)}$	$V_{GS} = -12\text{V}, I_D = 10\text{A}$	-	-	-3.10	V	
Drain to Source On Resistance	$r_{DS(ON)12}$	$I_D = 6\text{A}, V_{GS} = -12\text{V}$	$T_C = 25^\circ\text{C}$	-	0.190	0.280	Ω
			$T_C = 125^\circ\text{C}$	-	-	0.500	Ω
Turn-On Delay Time	$t_{d(ON)}$	$V_{DD} = -50\text{V}, I_D = 10\text{A}, R_L = 5.0\Omega, V_{GS} = -12\text{V}, R_{GS} = 7.5\Omega$	-	-	20	ns	
Rise Time	t_r		-	-	55	ns	
Turn-Off Delay Time	$t_{d(OFF)}$		-	-	45	ns	
Fall Time	t_f		-	-	35	ns	
Total Gate Charge (Not on slash sheet)	$Q_g(TOT)$	$V_{GS} = 0\text{V to } -20\text{V}$	$V_{DD} = -50\text{V}, I_D = 10\text{A}$	-	-	60	nC
Gate Charge at 12V	$Q_g(12)$	$V_{GS} = 0\text{V to } -12\text{V}$		-	36	40	nC
Threshold Gate Charge (Not on slash sheet)	$Q_g(TH)$	$V_{GS} = 0\text{V to } -2\text{V}$		-	-	2.5	nC
Gate Charge Source	Q_{gs}			-	6.6	7.4	nC
Gate Charge Drain	Q_{gd}			-	17	19	nC
Thermal Resistance Junction to Case	$R_{\theta JC}$			-	-	2.2	$^\circ\text{C/W}$
Thermal Resistance Junction to Ambient	$R_{\theta JA}$		-	-	60	$^\circ\text{C/W}$	

Source to Drain Diode Specifications

PARAMETER	SYMBOL	TEST CONDITIONS	MIN	TYP	MAX	UNITS
Forward Voltage	V_{SD}	$I_{SD} = 10A$	-0.6	-	-1.8	V
Reverse Recovery Time	t_{rr}	$I_{SD} = 10A, dI_{SD}/dt = 100A/\mu s$	-	-	160	ns

Electrical Specifications up to 100K RAD $T_C = 25^\circ C$, Unless Otherwise Specified

PARAMETER	SYMBOL	TEST CONDITIONS	MIN	MAX	UNITS
Drain to Source Breakdown Volts (Note 3)	BV_{DSS}	$V_{GS} = 0, I_D = 1mA$	-100	-	V
Gate to Source Threshold Volts (Note 3)	$V_{GS(TH)}$	$V_{GS} = V_{DS}, I_D = 1mA$	-2.0	-6.0	V
Gate to Body Leakage (Notes 2, 3)	I_{GSS}	$V_{GS} = \pm 20V, V_{DS} = 0V$	-	100	nA
Zero Gate Leakage (Note 3)	I_{DSS}	$V_{GS} = 0, V_{DS} = -80V$	-	25	μA
Drain to Source On-State Volts (Notes 1, 3)	$V_{DS(ON)}$	$V_{GS} = -12V, I_D = 10A$	-	-3.10	V
Drain to Source On Resistance (Notes 1, 3)	$r_{DS(ON)12}$	$V_{GS} = -12V, I_D = 6A$	-	0.280	Ω

NOTES:

1. Pulse test, 300 μs Max.
2. Absolute value.
3. Insitu Gamma bias must be sampled for both $V_{GS} = -12V, V_{DS} = 0V$ and $V_{GS} = 0V, V_{DS} = 80\% BV_{DSS}$.

Single Event Effects (SEB, SEGR) Note 4

TEST	SYMBOL	ENVIRONMENT (NOTE 5)			APPLIED V_{GS} BIAS (V)	(NOTE 6) MAXIMUM V_{DS} BIAS (V)
		ION SPECIES	TYPICAL LET (MeV/mg/cm)	TYPICAL RANGE (μ)		
Single Event Effects Safe Operating Area	SEESOAS	Ni	26	43	20	-100
		Br	37	36	10	-100
		Br	37	36	15	-80
		Br	37	36	20	-50

NOTES:

4. Testing conducted at Brookhaven National Labs; sponsored by Naval Surface Warfare Center (NSWC), Crane, IN.
5. Fluence = 1E5 ions/cm² (typical), $T_C = 25^\circ C$.
6. Does not exhibit Single Event Burnout (SEB) or Single Event Gate Rupture (SEGR).

Performance Curves

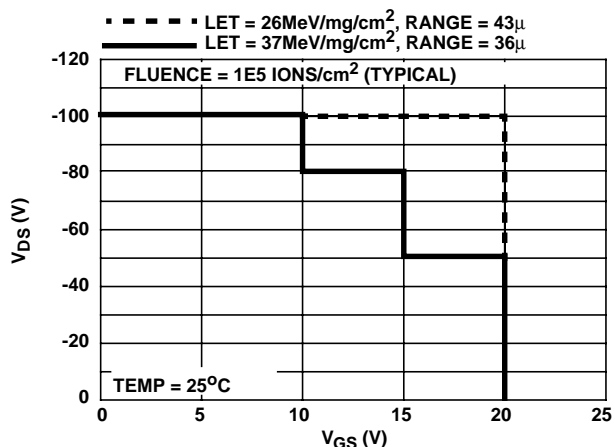


FIGURE 1. SINGLE EVENT EFFECTS SAFE OPERATING AREA

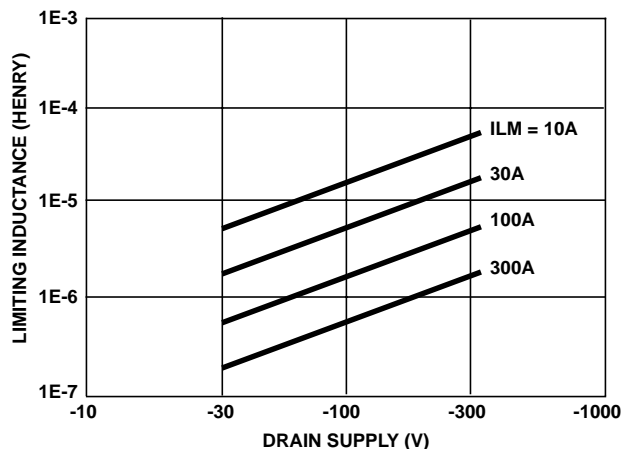


FIGURE 2. TYPICAL DRAIN INDUCTANCE REQUIRED TO LIMIT GAMMA DOT CURRENT TO I_{AS}

Performance Curves (Continued)

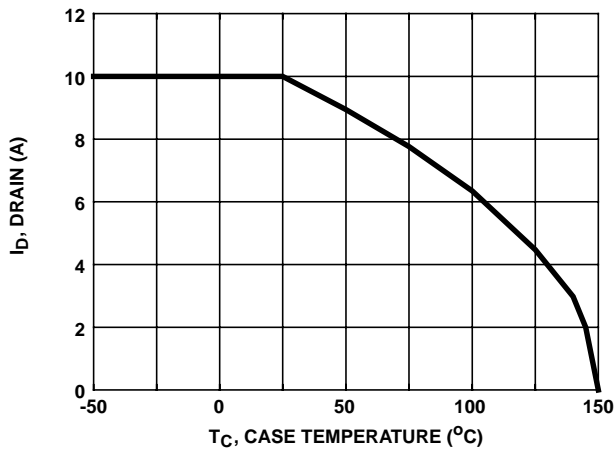


FIGURE 3. MAXIMUM CONTINUOUS DRAIN CURRENT vs TEMPERATURE

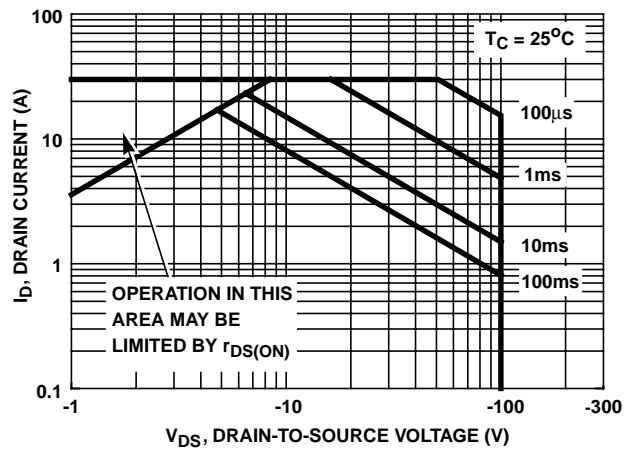


FIGURE 4. FORWARD BIAS SAFE OPERATING AREA

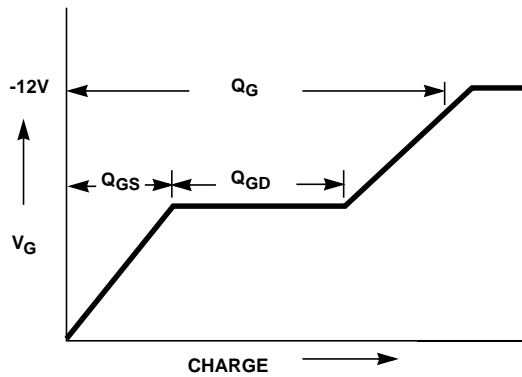


FIGURE 5. BASIC GATE CHARGE WAVEFORM

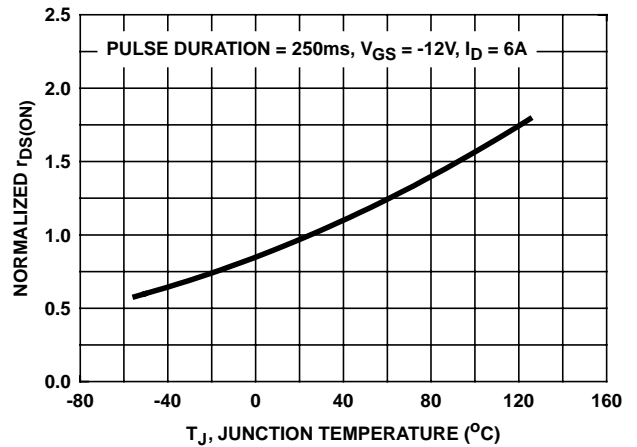


FIGURE 6. TYPICAL NORMALIZED $r_{DS(ON)}$ vs JUNCTION TEMPERATURE

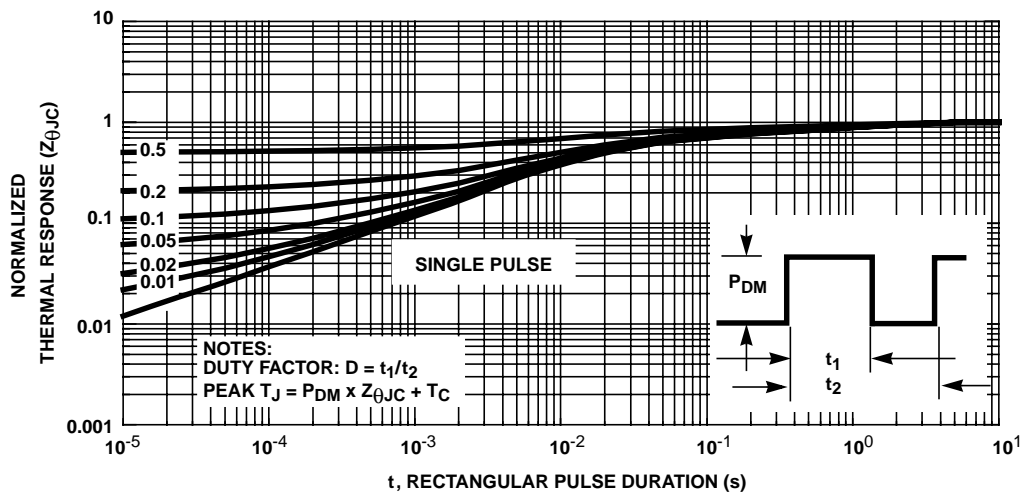


FIGURE 7. NORMALIZED MAXIMUM TRANSIENT THERMAL RESPONSE

Performance Curves (Continued)

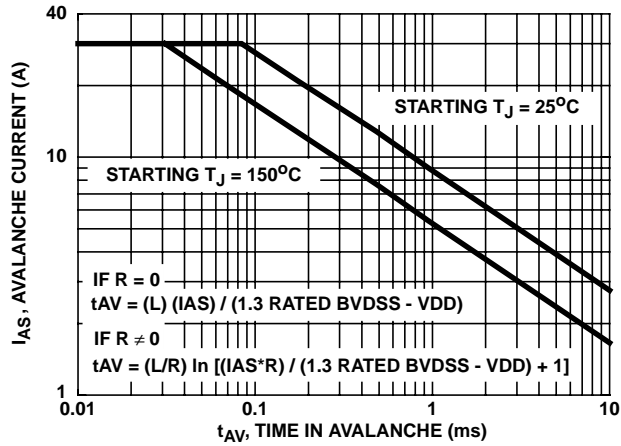


FIGURE 8. UNCLAMPED INDUCTIVE SWITCHING

Test Circuits and Waveforms

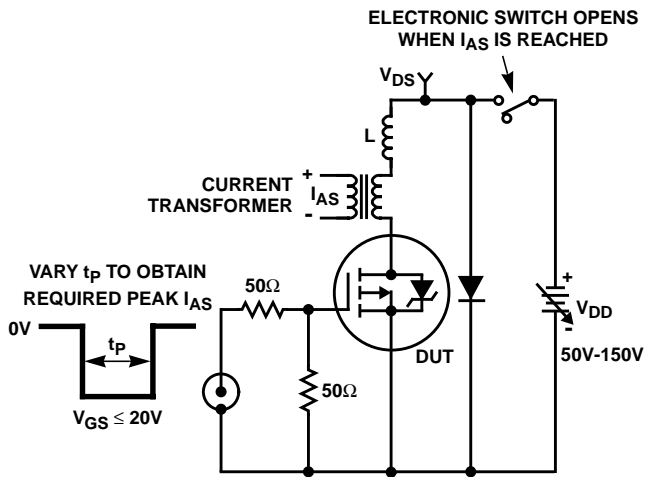


FIGURE 9. UNCLAMPED ENERGY TEST CIRCUIT

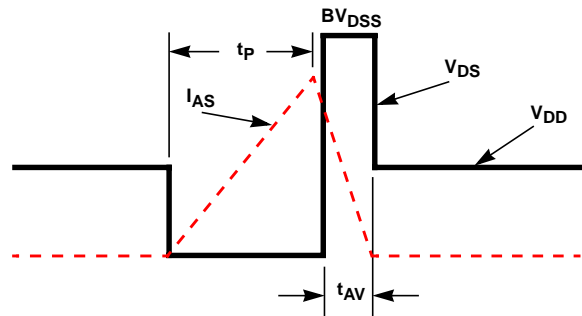


FIGURE 10. UNCLAMPED ENERGY WAVEFORMS

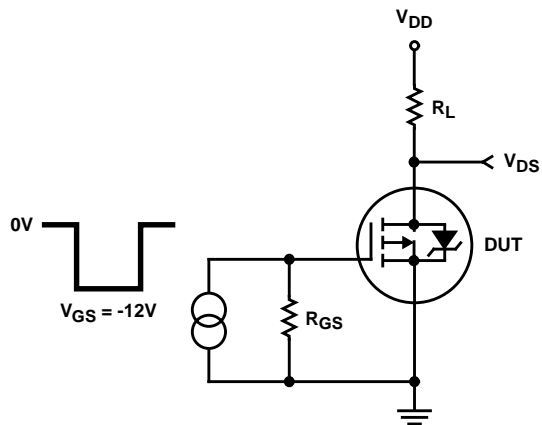


FIGURE 11. RESISTIVE SWITCHING TEST CIRCUIT

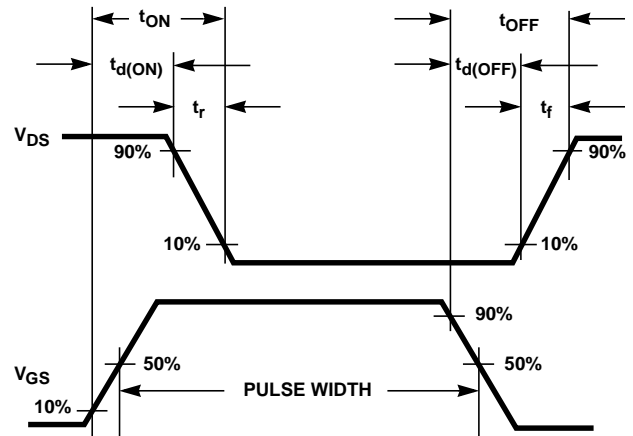


FIGURE 12. RESISTIVE SWITCHING WAVEFORMS

Screening Information

Screening is performed in accordance with the latest revision in effect of MIL-S-19500, (Screening Information Table).

Delta Tests and Limits (JANS) $T_C = 25^\circ\text{C}$, Unless Otherwise Specified

PARAMETER	SYMBOL	TEST CONDITIONS	MAX	UNITS
Gate to Source Leakage Current	I_{GSS}	$V_{GS} = \pm 20\text{V}$	± 20 (Note 7)	nA
Zero Gate Voltage Drain Current	I_{DSS}	$V_{DS} = 80\%$ Rated Value	± 25 (Note 7)	μA
Drain to Source On Resistance	$r_{DS(ON)}$	$T_C = 25^\circ\text{C}$ at Rated I_D	$\pm 20\%$ (Note 8)	Ω
Gate Threshold Voltage	$V_{GS(TH)}$	$I_D = 1.0\text{mA}$	$\pm 20\%$ (Note 8)	V

NOTES:

7. Or 100% of Initial Reading (whichever is greater).
8. Of Initial Reading.

Screening Information

TEST	JANS
Unclamped Inductive Switching	$V_{GS(PEAK)} = -15\text{V}$, $L = 0.1\text{mH}$; Limit = 30A
Thermal Response	$t_H = 100\text{ms}$; $V_H = -25\text{V}$; $I_H = 1\text{A}$; Limit = 85mV
Gate Stress	$V_{GS} = -30\text{V}$, $t = 250\mu\text{s}$
Pind	Required
Pre Burn-In Tests (Note 9)	MIL-S-19500 Group A, Subgroup 2 (All Static Tests at 25°C)
Steady State Gate Bias (Gate Stress)	MIL-STD-750, Method 1042, Condition B $V_{GS} = 80\%$ of Rated Value, $T_A = 150^\circ\text{C}$, Time = 48 hours
Interim Electrical Tests (Note 9)	All Delta Parameters Listed in the Delta Tests and Limits Table
Steady State Reverse Bias (Drain Stress)	MIL-STD-750, Method 1042, Condition A $V_{DS} = 80\%$ of Rated Value, $T_A = 150^\circ\text{C}$, Time = 240 hours
PDA	5%
Final Electrical Tests (Note 9)	MIL-S-19500, Group A, Subgroups 2 and 3

NOTE:

9. Test limits are identical pre and post burn-in.

Additional Screening Tests

PARAMETER	SYMBOL	TEST CONDITIONS	MAX	UNITS
Safe Operating Area	SOA	$V_{DS} = -80\text{V}$, $t = 10\text{ms}$	1.9	A
Thermal Impedance	ΔV_{SD}	$t_H = 500\text{ms}$; $V_H = -25\text{V}$; $I_H = 1\text{A}$	125	mV

Rad Hard Data Packages - Intersil Power Transistors

1. JANS Rad Hard - Standard Data Package

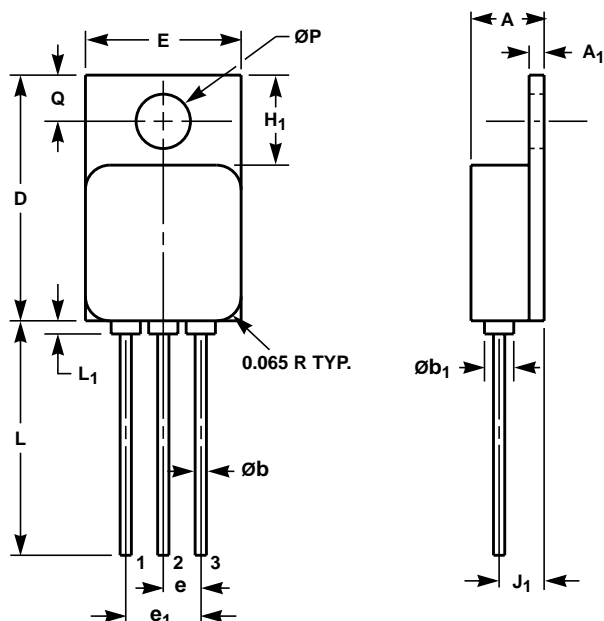
- A. Certificate of Compliance
- B. Serialization Records
- C. Assembly Flow Chart
- D. SEM Photos and Report
- E. Preconditioning - Attributes Data Sheet
 - Hi-Rel Lot Traveler
 - HTRB - Hi Temp Gate Stress Post Reverse Bias Data and Delta Data
 - HTRB - Hi Temp Drain Stress Post Reverse Bias Delta Data
- F. Group A - Attributes Data Sheet
- G. Group B - Attributes Data Sheet
- H. Group C - Attributes Data Sheet
- I. Group D - Attributes Data Sheet

2. JANS Rad Hard - Optional Data Package

- A. Certificate of Compliance
- B. Serialization Records
- C. Assembly Flow Chart
- D. SEM Photos and Report
- E. Preconditioning - Attributes Data Sheet
 - Hi-Rel Lot Traveler
 - HTRB - Hi Temp Gate Stress Post Reverse Bias Data and Delta Data
 - HTRB - Hi Temp Drain Stress Post Reverse Bias Delta Data
 - X-Ray and X-Ray Report
- F. Group A
 - Attributes Data Sheet
 - Hi-Rel Lot Traveler
 - Subgroups A2, A3, A4, A5 and A7 Data
- G. Group B
 - Attributes Data Sheet
 - Hi-Rel Lot Traveler
 - Subgroups B1, B3, B4, B5 and B6 Data
- H. Group C
 - Attributes Data Sheet
 - Hi-Rel Lot Traveler
 - Subgroups C1, C2, C3 and C6 Data
- I. Group D
 - Attributes Data Sheet
 - Hi-Rel Lot Traveler
 - Pre and Post Radiation Data

TO-257AA

3 LEAD JEDEC TO-257AA HERMETIC METAL PACKAGE



SYMBOL	INCHES		MILLIMETERS		NOTES
	MIN	MAX	MIN	MAX	
A	0.190	0.200	4.83	5.08	-
A ₁	0.035	0.045	0.89	1.14	-
$\varnothing b$	0.025	0.035	0.64	0.88	2, 3
$\varnothing b_1$	0.060	0.090	1.53	2.28	-
D	0.645	0.665	16.39	16.89	-
E	0.410	0.420	10.42	10.66	-
e	0.100 TYP		2.54 TYP		4
e ₁	0.200 BSC		5.08 BSC		4
H ₁	0.230	0.250	5.85	6.35	-
J ₁	0.110	0.130	2.80	3.30	4
L	0.600	0.650	15.24	16.51	-
L ₁	-	0.035	-	0.88	-
$\varnothing P$	0.140	0.150	3.56	3.81	-
Q	0.113	0.133	2.88	3.37	-

NOTES:

1. These dimensions are within allowable dimensions of Rev. B of JEDEC TO-257AA dated 9-88.
2. Add typically 0.002 inches (0.05mm) for solder coating.
3. Lead dimension (without solder).
4. Position of lead to be measured 0.150 inches (3.81 mm) from bottom of dimension D.
5. Die to base BeO isolated, terminals to case ceramic isolated.
6. Controlling dimension: Inch.
7. Revision 1 dated 1-93.

WARNING!

BERYLLIA WARNING PER MIL-S-19500

Packages containing beryllium oxide (BeO) shall not be ground, machined, sandblasted, or subject to any mechanical operation which will produce dust containing any beryllium compound. Packages containing any beryllium compound shall not be subjected to any chemical process (etching, etc.) which will produce fumes containing beryllium or its' compounds.

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